ELECTROSTATIC CHUCK WITH IMPROVED SPACING MASK AND WORKPIECE DETECTION DEVICE

Inventors: Vincent E. Burkhart; Allen Flanigan; Steven Sansoni, all of San Jose, Calif.


Notice: This patent is subject to a terminal disclaimer.

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Field of Search ......................... D15/140; 118/728; 279/128; 361/230-233, 234, 235

References Cited

U.S. PATENT DOCUMENTS

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Primary Examiner—Antoine Duval Davis
Attorney, Agent, or Firm—Thomason, Moser & Patterson

CLAIM

The ornamental design for an electrostatic chuck with improved spacing mask and workpiece detection device, as shown.

DESCRIPTION

FIG. 1 depicts a top view of the electrostatic chuck with improved spacing mask and workpiece detection device; FIG. 2 depicts an elevation view of the electrostatic chuck when looking up along the y-axis of FIG. 1; FIG. 3 depicts a detailed view of part of a surface and circumferential edge of the electrostatic chuck seen of FIG. 2; FIG. 4 depicts an elevation view of the electrostatic chuck when looking down along the y-axis of FIG. 1; FIG. 5 depicts an elevation view of the electrostatic chuck when looking to the left along the x-axis of FIG. 1, the view when looking to the right being a mirror image to that of FIG. 5; and, FIG. 6 is a bottom view of the electrostatic chuck.

1 Claim, 2 Drawing Sheets